Electronic Acknowledgement Receipt

EFS ID:	1274057
Application Number:	10678530
International Application Number:	
Confirmation Number:	1353
Title of Invention:	Semiconductor device and method for fabricating the same using damascene process
First Named Inventor/Applicant Name:	Chang-Huhn Lee
Customer Number:	20575
Filer:	Alexander Charles Johnson/Li Mei Vermilya
Filer Authorized By:	Alexander Charles Johnson
Attorney Docket Number:	8750-052
Receipt Date:	25-OCT-2006
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Application Type:	Utility

Payment information:

Submitted with Payment	no

File Listing:

Document Number	Document Description	File Name	File Size(Bytes)	Multi Part /.zip	Pages (if appl.)
1		8750052g.pdf	930950	yes	14

	Multipart Description/PDF files in .zip description		
	Document Description	**Start**	**End**
	Miscellaneous Incoming Letter	1	1
	Amendment - After Non-Final Rejection	2	9
	Applicant Arguments/Remarks Made in an Amendment	10	14
Warnings:			
Information:			
	Total Files Size (in bytes):	930950	

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New Applications Under 35 U.S.C. 111
If a new application is being filed and the application includes the necessary components for a filing date (see 37 CFR 1.53(b)-(d) and MPEP 506), a Filing Receipt (37 CFR 1.54) will be issued in due course and the date shown on this Acknowledgement Receipt will establish the filing date of the application.

National Stage of an International Application under 35 U.S.C. 371
If a timely submission to enter the national stage of an international application is compliant with the conditions of 35 U.S.C. 371 and other applicable requirements a Form PCT/DO/EO/903 indicating acceptance of the application as a national stage submission under 35 U.S.C. 371 will be issued in addition to the Filing Receipt, in due course.